

APPLICATION DATA SHEET

APPLICATION INFORMATION

Application Type::	REGULAR
Subject Matter::	UTILITY
CD-ROM or CD-R?:	NONE
Title::	SEMICONDUCTOR DEVICE HAVING METAL SILICIDE FILMS FORMED ON SOURCE AND DRAIN REGIONS AND METHOD FOR MANUFACTURING THE SAME
Attorney Docket Number::	247866US2S
Total Drawing Sheets::	5
Small Entity?:	NO

INVENTOR INFORMATION

Applicant Authority Type::	INVENTOR
Primary Citizenship Country::	Japan
Status::	FULL CAPACITY
Given Name::	Akira
Family Name::	HOKAZONO
City of Residence::	Sagamihara-shi
Country of Residence::	Japan
Street of Mailing Address::	c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome, Minato-ku
City of Mailing Address::	Tokyo
Country of Mailing Address::	Japan
Postal or Zip Code of Mailing Address::	105-8001

Applicant Authority Type:: INVENTOR
Primary Citizenship Country:: Japan
Status:: FULL CAPACITY
Given Name:: Kazuya
Family Name:: OHUCHI
City of Residence:: Yokohama-shi
Country of Residence:: Japan
Street of Mailing Address:: c/o Intellectual Property Division,
Toshiba Corporation,
1-1, Shibaura 1-chome, Minato-ku
City of Mailing Address:: Tokyo
Country of Mailing Address:: Japan
Postal or Zip Code of Mailing Address:: 105-8001

CORRESPONDENCE INFORMATION

Correspondence Customer Number:: 22850

REPRESENTATIVE INFORMATION

Representative Customer Number:: 22850

FOREIGN PRIORITY INFORMATION

Application Number:	Country::	Filing Date::	Priority Claimed::
2003-077648	Japan	03/20/03	YES